## 国際会議 2018 年度

• [10] 2018/11/14@ Kamakura in JPN

17th International Conference on Precision Engineering (ICPE2018)

Absolute measurement of optical path length of the three-dimensional nanoprofiler based on the normal vector tracing method by tandem white light interferometer

o J. Kang, T. Kitayama, R. Kizaki, T. Toyoshi, A. Winarno, K. Takamasu, K. Yamamura, K. Endo

• [9] 2018/11/08@ Las Vegas in USA

33rd American Society for Precision Engineering Annual Meeting (ASPE2018)

High Accuracy Cylindrical Mirror Measurement by Three-dimensional Nano-profiler Based on the Normal Vector Tracing Method

o J. Kang, H. Shiraji, R. Kizaki, T. Toyoshi, T. Kitayama, T. Miyawaki, K. Yamamura, K. Endo

[8] 2018/10/18@ St. Gallen in Switzerland

5th International Workshop Plasma Science & Interfaces

Adhesive-free strong adhesion between fluoropolymers and other materials via plasma-jet-treated polydimethylsiloxane

oY. Ohkubo, K. Endo, K. Yamamura

• [7] 2018/08/20@ Saskachewan in Canada

XRM2018 (International Conference X-ray Microscopy)

Multislice Imaging Of Integrated Circuits By X-Ray Ptychography

oK. Shimomura, M. Hirose, T. Higashino, Y. Takahashi

[6] 2018/08/20@ Saskachewan in Canada

XRM2018 (International Conference X-ray Microscopy)

Nanoscale Chemical Imaging of Three-Way Catalyst Pt/Ce2Zr2Ox Particles By Ptychographic-XAFS

o<u>M. Hirose,</u> N. Ishiguro, <u>K. Shimomura</u>, H. Matsui, M. Tada, <u>Y. Takahashi</u>

• [5] 2018/06/28@ NY in USA

Coherence 2018: International Workshop on Phase Retrieval and Coherence Scattering

Three-dimensional chemical imaging of oxygen storage and release particles by hard X-ray spectro-ptychography

o M. Hirose, N. Ishiguro, K. Shimomura, H. Matsui, M. Tada, Y. Takahashi

• [4] 2018/06/28@ NY in USA

Coherence 2018: International Workshop on Phase Retrieval and Coherence Scattering

Multislice observation of integrated circuits by X-ray ptychography

oK. Shimomura, M. Hirose, T. Higashino, Y. Takahashi

[3] 2018/06/13@ Taipei in Taiwan

SRI 2018: International Conference on Synchrotron Radiation Instrumentation

Development and application of hard X-ray spectro-ptychography using Kirkpatrick-Baez mirrors oM. Hirose, N. Ishiguro, K. Shimomura, H. Matsui, M. Tada, Y. Takahashi

• [2] 2018/06/07@ Venice in Italy

18th International Conference of the European Society for Precision Engineering and Nanotechnology Application of Plasma Chemical Vaporization Machining for Figuring of Reaction-sintered Silicon Carbide

oR. Sun, Y. Ohkubo, K. Endo, K. Yamamura

• [1] 2018/04/26@ Bilbao in Spain

The 19th CIRP Conference on Electro Physical and Chemical Machining

AFM observation of initial oxidation stage of 4H-SiC (0001) in electrochemical mechanical polishing

oX. Yang, Y. Ohkubo, K. Endo, K. Yamamura